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Photoelectron spectroscopy and *ab initio* calculations of small $Si_nS_m^-$ (n = 1,2; m = 1–4) clusters

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Binary cluster anions composed of silicon and sulfur elements, $\text{Si}_{n}\text{S}_{m}^{-}$ (n = 1,2; m = 1-4), were investigated by using photoelectron spectroscopy and *ab initio* calculations. The vertical detachment energies and the adiabatic detachment energies of these clusters were obtained from their photoelectron spectra. The electron affinity of SiS molecule is determined to be 0.477 ± 0.040 eV. The results show that the most stable structures of the anionic and neutral $\text{Si}_{n}\text{S}_{m}$ (n = 1,2; m = 1-4) clusters prefer to adopt planar configurations except that the structures of $\text{Si}_{2}\text{S}_{4}^{-}$ and $\text{Si}_{2}\text{S}_{2}$ are slightly bent. © 2014 AIP Publishing LLC. [http://dx.doi.org/10.1063/1.4896384]

I. INTRODUCTION

Silicon is one of the most abundant elements on the earth, which is very important in science and technology because of its various applications ranging from glass to catalysis to Si-based microelectronic devices.^{1,2} Sulfur is among the ten most abundant elements in the universe, therefore, is of great astrophysical interest.^{3–7} It is also an essential element for all life. Sulfur compounds largely exist in oil, animals, and plants.^{8,9} The pure silicon and sulfur clusters have been extensively studied both experimentally and theoretically,¹⁰⁻²¹ with investigations on their formation, stability, structures, and other physical/chemical properties. In the last decades, the molecules containing both silicon and sulfur have been the subjects of several experimental and theoretical investigations. Haas²² reported the preparations, properties, structures, and chemical reactions of silicon-sulfur compounds. He suggested that the various classes of compounds, such as disilyl sulfides, silanethiols, and organothiosilanes, can be derived from the chain structure of polymeric silicon disulfide. The theoretical calculations of Davy and Holiday²³ have predicted the lowest energy isomer of the SiS₂ cluster to be linear. Davy and Schaefer²⁴ predicted Si_2S as a singlet ring with C_{2v} symmetry by quantum-chemical calculations. Zheng and coworkers²⁵ found that silicon-sulfur cluster anions take SiS₂ as the growing unit and the sulfur atoms bridge the clustering silicon atoms. Wang et al.²⁶⁻²⁸ predicted that the clusters growing trend of $(SiS_2)_n^{\pm}$ bases on the binding of the Si and S atoms, with SiS_2^{\pm} as the core and SiS_2 as the unit. The calculations of Zwijnenburg et al.²⁹ suggested that the Si-S bonds in SiS₂ have a considerably more covalent character than the Si-O bonds in silica.

The silicon-sulfur mixed clusters have attracted much attention also because of their astronomical interest. In 1975, Zuckerman and co-workers³⁰ reported the first detection of SiS in the envelope of the carbon star IRC+10216 with a radio telescope of the National Radio Astronomy Observatory at Kitt Peak, Arizona. Recently, McCarthy *et al.*³¹ measured the rotational spectrum of Si₂S by Fourier transform microwave spectroscopy (FTMS) and obtained the accurate equilibrium structural parameters for Si₂S, which provides the spectroscopic foundation for an astronomical search for Si₂S. Gauss and co-workers³² determined the spectroscopic constants and equilibrium structure of cyclic SiS₂ associated with FTMS and high-level calculations. Their results indicate that cyclic SiS₂ is a local minimum and a plausible astronomical molecule, which may be detected with large radio telescopes in the future.

In this paper, we report a study on the electronic and geometric structures of small $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters with photoelectron spectroscopy and *ab initio* calculations.

II. EXPERIMENTAL AND THEORETICAL METHODS

A. Experimental method

The experiments were performed using a home-made apparatus consisting of a laser vaporization source, a time-offlight (TOF) mass spectrometer, and a magnetic-bottle photoelectron spectrometer, which has been described previously.³³ Briefly, the $Si_nS_m^{-}$ (n = 1,2; m = 1-4) cluster anions were produced in the laser vaporization source by laser ablation of a rotating and translating disk target (13 mm diameter, Si:S mole ratio 4:1) with the second harmonic (532 nm) light pulses from a nanosecond Nd:YAG laser (Continuum Surelite II-10). Helium gas with \sim 4 atm backing pressure was allowed to expand through a pulsed valve (General Valve Series 9) into the source to cool the formed clusters. The generated cluster anions were mass-analyzed by the TOF mass spectrometer. The clusters of interest were mass-selected and decelerated before being photodetached by another laser beam. We used three types of photon energies for the photodetachment: 1064 nm and 266 nm from a Nd: YAG laser (Continuum Surelite II-10) and 193 nm (ArF) from an excimer laser. The

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photodetached electrons were energy-analyzed by the magnetic-bottle photoelectron spectrometer. The photoelectron spectra were calibrated using the spectra of Cu^- and I^- taken at similar conditions. The resolution of the photoelectron spectrometer was approximately 40 meV for electrons with 1 eV kinetic energy.

B. Theoretical method

The geometry optimizations and frequency calculations of $Si_nS_m^{-}$ (n = 1,2; m = 1-4) and their neutral counterparts were carried out using Density Functional Theory (DFT) with the Becke's three-parameter and Lee-Yang-Parr's gradientcorrected correlation hybrid functional (B3LYP).^{34,35} The aug-cc-pVTZ basis set³⁶ is used for both Si and S. This theoretical method has been shown to be suitable for silicon-sulfur clusters in previous reports.^{29,31} All the geometry optimizations were conducted without any symmetry constraint. Harmonic vibrational frequencies were calculated to make sure that the optimized structures correspond to real local minima. The single-point energies, vertical detachment energies (VDEs), and adiabatic detachment energies (ADEs) of the different isomers were also calculated by using the coupledcluster singles and doubles augmented by a perturbative treatment of triple excitations [CCSD(T)]³⁷ method with the same basis set. The calculated energies were corrected by the zeropoint vibrational energies (ZPEs) from the B3LYP calculations with the same basis set. The VDEs were calculated as the energy differences between the neutrals and the anions at the geometries of the anionic species. The ADEs were obtained as the energy differences between the neutrals and the anions with the neutral structures relaxed to the nearest local minima related to the anionic structures. All theoretical calculations in this work were performed with Gaussian 09 program package.38

III. RESULTS AND DISCUSSION

A. Photoelectron spectra

The photoelectron spectra of SiS_m^- (m = 1-4) taken with 193 nm (6.424 eV) and 266 nm (4.661 eV) photons are presented in Figure 1, and those of $Si_2S_m^-$ (m = 1-4) are shown in Figure 2. Figure 3 shows the photoelectron spectrum of SiS⁻ at 1064 nm (1.165 eV). The spectra recorded with 193 nm photons show the spectral features at higher binding energy, while those at 266 nm and 1064 nm give better spectral resolution for the low electron binding energy peaks. The VDEs and the ADEs of the $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters obtained from their photoelectron spectra are listed in Table I. The VDE of each cluster was taken from the maxima of the first peak in its spectrum. The ADE of each cluster was determined by adding the value of instrumental resolution to the onset of the first peak in its spectrum. The onset of the first peak was determined by drawing a straight line along the leading edge of the first peak to cross the baseline of the spectrum.

According to the spectra in Figures 1 and 2, we can see that the VDEs of the SiS_m^- and $Si_2S_m^-$ (m = 1-4) clusters increase with increasing number of sulfur atoms.



FIG. 1. Photoelectron spectra of ${\rm SiS_m}^-$ (m = 1-4) clusters recorded with 266 nm and 193 nm photons.

1. SiS_m^- (*m* = 1-4)

We measured the photoelectron spectrum of SiS⁻ at 193, 266, and 1064 nm. In the 193 nm spectrum of SiS⁻, there are three major bands centered at 0.57, 3.87, and 4.78 eV, respectively. The second band at 3.87 eV is split into three resolved peaks centered at 3.868, 3.937, and 4.006 eV in the 266 nm spectrum. The spacing of these three peaks is approximately $0.069 \text{ eV} (557 \text{ cm}^{-1})$, which corresponds to the vibrational frequency of the first electronic excited state of SiS $({}^{3}\Pi_{1})$. In the 1064 nm spectrum of SiS⁻, five resolved peaks are observed, which correspond to the first band of the spectra taken with 193 and 266 nm. The five sharp peaks centered at 0.477, 0.566, 0.657, 0.758, 0.865 eV can be tentatively assigned to the vibrational progression related to the transition from the ground state of SiS⁻ to the electronic ground state $(^{1}\Sigma^{+})$ of SiS neutral. The separation of the vibrational progression is about 0.097 eV (780 cm⁻¹), which is in agreement with the vibrational frequency ($\omega_e = 749.6 \text{ cm}^{-1}$) of SiS ($^{1}\Sigma^{+}$) reported by Harris et al.³⁹

Four major bands centered at 2.64, 4.10, 5.23, and 6.12 eV are observed in the spectrum of SiS_2^- at 193 nm. The first band is determined more precisely to be 2.79 eV in the 266 nm spectrum. The second band at 4.10 eV is split into two resolved peaks centered at 3.96 and 4.34 eV at 266 nm. In the spectrum of SiS_3^- , we are able to distinguish two bands



FIG. 2. Photoelectron spectra of ${\rm Si_2S_m}^-$ (m = 1-4) clusters recorded with 266 nm and 193 nm photons.



FIG. 3. Photoelectron spectrum of SiS⁻ cluster recorded with 1064 nm photons. The solid line stands for the experimental data. The red dashed line comes from the Franck-Condon simulation. The temperature of SiS⁻ cluster is set at 600 K. The geometries and vibration frequencies of anion SiS⁻ and neutral SiS calculated at B3LYP/aug-cc-pVTZ level are utilized in FC simulation.

TABLE I. Experimental VDEs and ADEs of $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters estimated from their photoelectron spectra.^a

Cluster	VDE (eV)	ADE (eV)
SiS ⁻	0.566 ± 0.040	0.477 ± 0.040
SiS ₂ ⁻	2.79 ± 0.08	2.34 ± 0.08
SiS ₃ ⁻	4.00 ± 0.08	3.92 ± 0.08
SiS ₄ ⁻	4.39 ± 0.08	4.08 ± 0.08
Si ₂ S ⁻	1.65 ± 0.08	1.37 ± 0.08
$\tilde{Si_2S_2}^-$	1.68 ± 0.08	1.50 ± 0.08
Si ₂ S ₃ ⁻	2.02 ± 0.08	1.76 ± 0.08
$Si_2S_4^-$	3.36 ± 0.08	2.84 ± 0.08

^aThe VDE and ADE of SiS⁻ are estimated from its 1064 nm photoelectron spectrum. The VDE and ADE of SiS₄⁻ are estimated from its 193 nm photoelectron spectrum. Those of the others Si_nS_m⁻ clusters are estimated from their 266 nm photoelectron spectra.

centered at 4.00 and 4.51 eV. Due to the higher electron binding energy of SiS_4^- , only the 193 nm photoelectron spectrum for SiS_4^- was taken. As shown in Figure 1, the photoelectron spectrum of SiS_4^- has three resolved peaks centered at 4.39, 4.68, and 5.26 eV, respectively.

2. $Si_2S_m^-$ (m = 1-4)

The spectrum of Si_2S^- at 193 nm has five features centered at 1.65, 2.58, 3.70, 4.16, and 4.73 eV, respectively. The second feature at 2.58 eV is split into two peaks centered at 2.45 and 2.78 eV in the 266 nm spectrum. There are more than five bands in the $Si_2S_2^-$ spectrum at 193 nm, and the first two bands centered at 1.68 and 2.31 eV are weaker than the others. The spectrum of $Si_2S_3^-$ at 193 nm contains two major bands, in which one centered at 2.02 eV is clearly resolved and another higher energy band has three barely resolved peaks centered at 4.53, 4.88, and 5.53 eV, respectively. The spectrum of $Si_2S_4^-$ at 193 nm exhibits three bands centered at 3.27, 4.79, and 5.62 eV, respectively. The first band is determined more precisely to be 3.36 eV in the 266 nm spectrum.

B. Theoretical results

The optimized geometries of the low-lying isomers of the $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters are presented in Figure 4 with the most stable structures on the left. Figure 5 displayed the optimized geometries of the low-lying isomers of the neutral Si_nS_m (n = 1,2; m = 1-4) clusters with the most stable structures on the left. We have considered many different initial structures and multiplicities in the calculations. The Cartesian coordinates of the low-lying isomers of $Si_nS_m^-$ (n = 1,2; m = 1-4) are available in the supplementary material.⁴⁰

The symmetries, relative energies, and theoretical VDEs and ADEs of these low-lying anionic isomers are summarized in Table II along with the experimental VDEs and ADEs for comparison. The VDEs of the most stable isomers calculated with the CCSD(T) method are in excellent agreement with the experimental values. The harmonic vibrational frequencies as well as the infrared intensities, dipole moments, and rotational constants of the most stable Si_nS_m neutral clusters at the B3LYP/aug-cc-pVTZ level are available in the



FIG. 4. Geometries of the low-lying isomers of $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters optimized at B3LYP/aug-cc-pVTZ level. The energies relative to the most stable isomers are obtained by using the CCSD(T) method. Bond lengths (in angstrom) and bond angels (in degree) are also shown.

supplementary material.⁴⁰ We have also simulated the photoelectron spectra of different isomers based on theoretically generalized Koopmans' theorem (GKT)^{41,42} and compared the simulated spectra with the experimental results in Figure 6. For convenience, we call the simulated spectra as density of states (DOS) spectra.⁴² Each transition, as the vertical lines in the DOS spectra, corresponds to the removal of an electron from a specific molecular orbital of the cluster anion. In the simulation, the first peak associated with the HOMO was set at the position of theoretical VDE, and the other peaks associated with the deeper orbitals were shifted to higher binding energies side according to the relative energies of orbitals (ΔE_n). The values of ΔE_n were calculated by the equation: $\Delta E_n = E_{(HOMO)} - E_{(HOMO-n)}$, where $E_{(HOMO)}$ is the energy of the HOMO, $E_{(HOMO-n)}$ is the energy of the HOMO-n orbital from theoretical calculations. The peak associated with each orbital was fitted with a unit-area Gaussian function of 0.2 eV full width at half maximum (FWHM). It should be noted that the theoretical VDEs discussed in the following paragraphs are from the CCSD(T) calculations and



FIG. 5. Geometries of the low-lying isomers of Si_nS_m (n = 1,2; m = 1-4) clusters optimized at B3LYP/aug-cc-pVTZ level. The energies relative to the most stable isomers are obtained by using the CCSD(T) method. Bond lengths (in angstrom) and bond angels (in degree) are also shown.

the DOS spectra of $Si_nS_m^-$ (n = 1,2; m = 1-4) are produced at the CCSD(T) /aug-cc-pVTZ level.

1. Structures of SiS_m^- and SiS_m (m = 1-4)

a. SiS^- and SiS. SiS^- is of $C_{\infty v}$ symmetry with a ${}^2\Pi$ electronic state. The calculated Si–S bond length of SiS^- is 2.04 Å. The theoretical VDE (0.60 eV) of SiS^- is in good agreement with the experimental value (0.566 eV). In Figure 6, the DOS spectrum of 1A is also very similar to the experimental spectrum of SiS^- . For the ground state of the neutral SiS (1a), our calculations show that the Si–S bond length is 1.94 Å, shorter than that of the anion by 0.10 Å. The Si–S bond of SiS is longer than the calculated Si–O bond (1.54 Å) of its isoelectronic SiO molecule by ~0.40 Å.⁴³ The calculated vibrational

					VDE (eV)			ADE(eV)		
					Theo.			Theo.		
Isomer		State	Sym.	$\Delta E^{a} (eV)$	B3LYP	CCSD(T)	Expt.	B3LYP	CCSD(T)	Expt.
SiS ⁻	1A	² Π	C	0.00	0.76	0.60	0.566	0.64	0.50	0.477
SiS2 ⁻	2A	${}^{2}A_{1}$	$\widetilde{C_{2v}}$	0.00	2.82	2.67	2.79	1.95	1.81	2.34
	2B	${}^{2}B_{2}$	C_{2v}	0.79	3.07	3.10		2.01	1.80	
SiS ₃ ⁻	3A	${}^{2}A_{2}^{'}$	D _{3h}	0.00	4.43	4.02	4.00	3.28	2.92	3.92
	3B	${}^{2}\bar{A'}$	C _s	1.02	3.08	2.95		2.03	1.90	
	3C	$^{2}A^{\prime\prime}$	C _s	1.49	3.17	3.35		3.01	2.98	
SiS ₄ ⁻	4 A	$^{2}A^{\prime\prime}$	C s	0.00	4.19	4.51	4.39	3.84	3.92	4.08
	4B	$^{2}A'$	C _s	0.28	3.69	3.79		2.61	2.37	
	4C	${}^{4}A_{2}$	D _{2d}	1.44	4.31	3.94		2.68	2.50	
Si_2S^-	5A	${}^{2}B_{1}$	C_{2v}^{2u}	0.00	1.74	1.65	1.65	1.56	1.48	1.37
	5B	² П	C _{∞v}	0.48	2.25	2.29		2.16	2.20	
	5C	${}^{4}A''$	C _s	1.07	2.07	2.16		1.57	1.59	
Si ₂ S ₂ ⁻	6A	${}^{2}B_{1g}$	D _{2h}	0.00	1.74	1.64	1.68	1.63	1.52	1.50
	6B	${}^{2}A_{1}$	C _{2v}	0.001	2.29	2.22		1.55	1.52	
	6C	${}^{2}A''$	Č,	0.26	2.41	2.33		2.19	2.12	
Si ₂ S ₃ ⁻	7A	${}^{2}A_{2}''$	D _{3h}	0.00	2.93	2.78		2.81	2.65	
	7B	${}^{2}B_{1}$	C_{2v}	0.01	2.11	2.07	2.02	1.91	1.82	1.76
	7C	$^{2}A'$	Č,	1.02	3.54	3.98		2.69	2.59	
$\mathrm{Si}_{2}\mathrm{S}_{4}^{-}$	8A	$^{2}A'$	C _s	0.00	3.44	3.34	3.36	2.38	2.24	2.84
	8B	${}^{2}B_{1}$	C_{2v}	0.54	4.17	4.09		2.79	2.56	
	8C	$^{2}A'$	Č,	1.12	3.79	3.67		2.52	2.33	

TABLE II. Relative energies, theoretical VDEs and ADEs of the low-lying isomers of $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters, as well as the experimental VDEs and ADEs estimated from their photoelectron spectra. The isomers labeled in bold are the most probable isomers in the experiments.

^aThe ΔE values are from the CCSD(T) method.

frequency of SiS (1a) is 741 cm^{-1} , which is in agreement with the vibrational spacing (780 cm^{-1}) observed experimentally in this work (Figure 3) and the result (749.6 cm^{-1}) reported by Harris et al.³⁹ We find an electronic excited state of the neutral SiS (2b), which is higher than the ground state of SiS by 3.30 eV in energy (Figure 5). The calculated results in Table II and Figure 5 indicate that the energies of SiS ${}^{1}\Sigma^{+}$ and SiS ${}^{3}\Pi_{1}$ relative to the ground state of SiS⁻ (${}^{2}\Pi$) are 0.50 and 3.80 eV, respectively. They are consistent with the positions of the first two bands in the spectra of 193 and 266 nm. The calculated vibrational frequency of the excited state (SiS ${}^{3}\Pi_{1}$) is 583 cm⁻¹, which is in agreement with the separation (557 cm^{-1}) of the second band in the range of 3.80-4.20 eV in the 266 nm spectrum of SiS⁻. It should be noted that the second band of SiS⁻ in the range of 3.45-4.20 eV at 266 nm also includes several electronic excited states and the rising edge (3.45-3.80 eV) of the band may be attributed to the hot bands, similar to the hot bands in the spectrum of 1064 nm.

In order to verify the assignment of the vibrational progression in the 1064 nm spectrum, Franck-Condon (FC) simulation was performed by using the ezSpectrum program⁴⁴ to assure the $0 \leftarrow 0$ band of SiS (X ${}^{1}\Sigma^{+}$) \leftarrow SiS⁻ (X ${}^{2}\Pi$) transition using the frequencies and geometries of SiS (X ${}^{1}\Sigma^{+}$) and SiS⁻ (X ${}^{2}\Pi$) calculated at B3LYP/aug-cc-pVTZ level (Figure 3). In the spectrum simulation, a FWHM of 440 cm⁻¹ was utilized with Gaussian band envelopes. The red dashed line in Figure 3 is the simulation result by setting the temperature of the SiS⁻ anion at 600 K, which is in good agreement with the experiment data with slightly difference for the onset. The position of $0 \leftarrow 0$ transition, which stands for the adiabatic detachment energy of SiS⁻ or the electron affinity of the neutral SiS, is determined to be 0.477 ± 0.040 eV and corresponds to the transition from the vibrational ground state of SiS⁻ to that of the neutral SiS. The second peak, which stands for the vertical detachment energy of SiS⁻, is determined to be 0.566 ± 0.040 eV. The hot bands are slightly serious in the experimental spectrum. The probable reason is that the SiScluster is hot in our experiments due to its small size. This is confirmed by the FC simulation as the temperature of the anion is about 600 K in the FC simulation. Note that the temperature of the SiS⁻ was high because it is of small size and had experienced few collisions in the molecular beam while the temperatures of the larger Si_nS_m⁻ clusters were lower because they had experienced more collisions in the molecular beam.

b. SiS_2^- and SiS_2 . We have found two low-lying isomers for SiS_2^- , which are both S-Si-S bent structures with C_{2v} symmetry in different electronic states. The Si–S bond length of isomer 2A is 2.03 Å. The ∠SSiS bond angle of isomer 2A in ²A₁ electronic state is 133.6°, similar to the ∠OSiO bond angle (140°) of its isoelectronic SiO_2^- anion.⁴⁵ The ∠SSiS bond angle of isomer 2B is about 90.7°, similar to the stable structure of SiS_2^- reported by Wang *et al.*²⁷ In our work, the energy of isomer 2B is higher than that of isomer 2A by 0.79 eV, and the predicted VDE (3.10 eV) of isomer 2B is much higher than the experimental value (2.79 eV). The



FIG. 6. Comparison of the experimental photoelectron spectra of $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters with their simulated DOS spectra at CCSD(T)/aug-ccpVTZ level. The simulations were conducted by fitting the distribution of the transition lines with unit-area Gaussian functions of 0.2 eV full width at half maximum. The vertical lines are the theoretical simulated spectral lines of $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters.

calculated VDE of isomer 2A is 2.67 eV, in excellent agreement with the experimental measurement. In Figure 6, the simulated DOS spectrum of isomer 2A also agrees with the experimental spectrum. Therefore, we can infer that isomer 2A is the most likely structure of SiS_2^- in our experiments. Although isomer 2B is a real minimum on the SiS_2^-

potential energy surface, it cannot exist in our experiments due to its high energy. For the neutral SiS₂, the most stable isomer 2a is a S-Si-S linear structure with $D_{\infty h}$ symmetry, similar to CS₂ and SiO₂, and consistent with Walsh rule's^{32,46} as well as the result obtained by Davy and Holiday.²³ Its Si–S bond length is 1.93 Å, which is shorter than that of isomer 2A. For isomer 2b, the \angle SSiS angle is 61.5°, smaller than those of isomers 2A and 2B.

c. SiS_3^{-} and SiS_3^{-} . We obtained three low-lying isomers for SiS₃⁻. The most stable structure of SiS₃⁻ (3A) is of D_{3h} symmetry without any S-S bond and the Si-S bond length is 2.03 Å. Isomer 3B is a non-planar C_s structure without any S–S bond. Isomer 3C is a *trans*-planar structure of C_s symmetry. The theoretical VDE (4.02 eV) of isomer 3A is in good agreement with the experimental measurement (4.00 eV). The energies of isomers 3B and 3C are 1.02 eV and 1.49 eV higher than that of isomer 3A, respectively. The simulated DOS spectrum of isomer 3A is in better agreement with the experimental spectrum than those of isomers 3B and 3C. Then, we suggest that isomer 3A is the most likely structure for SiS_3^{-} . For the neutral SiS₃, the most stable isomer 3a is a Y-shaped structure with C_{2v} symmetry. There are two kinds of Si–S bonds and the bond lengths are 1.94 and 2.09 Å, respectively. Isomer 3b is a four-membered ring structure of C_{2v} symmetry. Isomer 3c with C_{2v} symmetry is similar to the structure of isomer 3A.

d. SiS_4^- and SiS_4^- . For SiS_4^- , the most stable isomer (4A) has C_s symmetry. The fourth sulfur atom attaches to one of three sulfur atoms of SiS_3^{-} . The structure of isomer 4B is similar to that of isomer 4A with slightly difference in ∠SSSi angle. Isomer 4C is a 3D structure with two SiS₂ subunits perpendicular to each other. The calculated VDE of isomer 4A is 4.51 eV, which is consistent with the experimental value (4.39 eV). The energies of isomers 4B and 4C are 0.28 eV and 1.44 eV higher than that of isomer 4A, respectively, and their theoretical VDEs are different from the experimental measurement. The simulated DOS spectrum of isomer 4A is also consistent with the experimental spectrum. Therefore, isomer 4A is what we observed in our experiments. For SiS_4 neutral, isomer 4a has a four-membered ring SiS₃ and with an additional S atom attaching to the Si atom. Isomer 4b is a 3D configuration with D_{2d} symmetry, which is similar to isomer 4C. Isomer 4c is a distorted five-membered ring structure with C₂ symmetry.

2. Structures of $Si_2S_m^-$ and Si_2S_m (m = 1-4)

a. Si_2S^- and Si_2S . For Si_2S^- , the most stable isomer (5A) is an isosceles triangle structure with C_{2v} symmetry. The Si-S bond length of isomer 5A is 2.24 Å, longer than that of SiS_2^- (2.03 Å), and the \angle SiSSi angle is 61.3°. Isomer 5B is a Si-Si-S linear structure with $C_{\infty v}$ symmetry and isomer 5C is a Si-Si-S bent structure. The calculated VDE (1.65 eV) of isomer 5A is in excellent agreement with the experimental value (1.65 eV). The simulated DOS spectrum of isomer 5A is also in good agreement with the experimental spectrum of Si_2S^- . The VDEs of isomers 5B and 5C deviate from our experimental result. And the energies of isomers 5B and 5C are much higher than that of isomer 5A. Therefore, the existence of isomers 5B and 5C in our experiments can be ruled out. Isomer 5A is the most probable one detected in our experiments. For the neutral Si_2S , the most stable isomer (5a) is an isosceles triangle structure in ¹A₁ state, consistent with the predicted structure by Davy and Schaefer.²⁴ The Si-S bond length of isomer 5a is 2.16 Å, shorter than that of isomer 5A, and the \angle SiSSi angle is 67.9°. Isomer 5b is also an isosceles triangle structure in ³B₁ electronic state. The Si–S bond length of isomer 5b is 2.21 Å, slightly shorter than that of isomer 5A, and the \angle SiSSi angle is 63.4°. The structure of isomer 5c is linear (Si-Si-S) with C_{∞v} symmetry.

b. $Si_2S_2^-$ and Si_2S_2 . The first two isomers of $Si_2S_2^-$ are nearly degenerate in energy, with isomer 6B higher than isomer 6A by only 0.001 eV. Isomer 6A is a rhombus structure with alternating Si-S bonds, and has D_{2h} symmetry with a ${}^{2}B_{1g}$ electronic state. The Si–S bond length of isomer 6A is 2.22 Å. Isomer 6B is a non-planar four-membered ring (dihedral angle of S-SiSi-S is about 121°) of C_{2v} symmetry. The calculated VDE (1.64 eV) of isomer 6A is in good agreement with the experimental measurement (1.68 eV). The theoretical VDE of isomer 6B is calculated to be 2.22 eV, much higher than that of the first peak (1.68 eV) in the experimental spectrum of $Si_2S_2^{-}$, but fits the feature in the range of 1.92-2.60 eV very well. The energy of isomer 6C is higher than that of isomer 6A by 0.26 eV and its theoretical VDE is very different from our experimental result. As we can see in Figure 6, the simulated DOS spectrum of isomer 6A may contribute to a part of photoelectron features and that of isomer 6B agrees well with other part in the experimental spectrum of $Si_2S_2^{-}$. The combination of the DOS spectra of isomers 6A and 6B can fit the experimental spectrum very well. As a result, we suggest that isomers 6A and 6B coexist in our experiments. For Si_2S_2 neutral, the structure of isomer 6a is a non-planar four-membered ring (dihedral angle of S-SiSi-S is about 151°) with a ${}^{1}A_{1}$ electronic state. It is the only nonplanar structure among the most stable isomers of Si_nS_m (n = 1,2; m = 1-4) neutrals. The slightly folding of the Si_2S_2 rhumbus probably is due to repulsion of the Si-S bonds by the non-bonding valent electrons of the Si atoms. Isomer 6b is a planar structure, which consists of a three-membered ring Si_2S and a Si=S double bond. Isomer 6c is a rhombus D_{2h} structure.

c. $Si_2S_3^-$ and Si_2S_3 . We displayed three low-lying isomers for Si₂S₃⁻. Isomer 7A is a D_{3h} symmetric trigonal bipyramid with the two silicon atoms capping on the opposite sides of the plane formed by the three sulfur atoms. Isomer 7B is a planar structure with C_{2v} symmetry, has a Si₂S₂ four-membered ring and the third S atom attaching to one of the Si atoms in the Si₂S₂ ring. Isomer 7B lies only 0.01 eV above isomer 7A. Isomer 7C is a W-shaped structure with alternating S-Si bonds. The energy of isomer 7C is higher than that of isomer 7A by 1.02 eV, and its theoretical VDE (3.98 eV) is very different from our experimental result (2.02 eV). The calculated VDE of isomer 7B is 2.07 eV, in excellent agreement with the experimental measurement. In Figure 6, we can see that the simulated DOS spectrum of isomer 7B fits well with the experimental spectrum of $Si_2S_3^{-}$. Although the theoretical VDE (2.78 eV) of isomer 7A is different from the experimental value, its DOS spectrum may contribute to some of the signals in the range of 2.60-4.00 eV in the experimental spectrum. Thus, we suggest that isomer 7B is the dominant structure in our experiments, and isomer 7A may contribute to

some of the low intensity peaks in the experimental spectra. For the neutral Si_2S_3 , the most stable structure (isomer 7a) is similar to isomer 7B of the anion, and the second stable structure (isomer 7b) is similar to isomer 7A of the anion. Isomer 7c is a five-membered ring with C_{2v} symmetry. As we can see in Figure 5, the trigonal bipyramid structure (7b) is much less stable than the planar structure (7a). Since isomer 7a is much more stable than the other isomers, it may have a larger population in our cluster source. And it is easy for isomer 7a of the Si_2S_3 neutral to get an electron to form isomer 7B of the $Si_2S_3^-$ anion. This probably can explain why isomer 7B is the dominant isomer of the anion that contributed to the experimental spectrum of $Si_2S_3^-$.

d. $Si_2S_4^{-}$ and $Si_2S_4^{-}$. We obtained three low-lying isomers for $Si_2S_4^{-}$. Isomer 8A has C_s symmetry. It is the only nonplanar structure among the most stable isomers of $Si_nS_m^{-}$ (n = 1,2; m = 1-4). It can be viewed as two S atoms attaching to a Si_2S_2 four-membered ring. It has two bridging S atoms and two terminal S atoms. One of the terminal S atoms is bent out of the plane due to the repulsion from the negative charge, similar to the case of $Si_2O_4^{-}$.⁴⁵ Isomer 8B has C_{2v} symmetry with a Si₂S₂ rhombus and a SiS₂ subunit perpendicular to the plane of the Si_2S_2 rhombus, which is similar to the most stable structure of $Si_2S_4^-$ calculated by Wang *et al.*²⁷ However, we found that isomer 8A is the most stable structure of $Si_2S_4^{-}$ rather than isomer 8B. Isomer 8C has C_s symmetry with a five-membered ring Si_2S_3 and a terminal Si–S bond. The theoretical VDE of isomer 8A is 3.34 eV, which is consistent with the experimental value (3.36 eV). The energies of isomers 8B and 8C are both much higher than that of isomer 8A, and their calculated VDEs deviate from our experimental result. In Figure 6, the simulated DOS spectrum of isomer 8A is much more similar to the observed spectrum of $Si_2S_4^{-1}$ than those of isomers 8B and 8C. Therefore, the existence of isomers 8B and 8C in our experiments can be ruled out. Isomer 8A is the most probable one detected in our experiments. For the neutral Si_2S_4 , its ground state structure (8a) has a D_{2h} planar structure with a Si_2S_2 rhombus and two terminal Si=Sdouble bonds, which is in agreement with the calculated result by Wang et al.²⁸ The structure of isomer 8b is similar to that of isomer 8B, which includes a Si_2S_2 rhombus and a SiS_2 subunit perpendicular to the plane of the rhombus. The structure of isomer 8c is planar with a five-membered ring and a terminal Si=S double bond.

In summary, the most stable isomers of the anionic $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters are all planar structures except for $Si_2S_4^-$. The most stable structures of the neutral Si_nS_m (n = 1,2; m = 1-4) clusters are all planar with the exception of Si_2S_2 . As we can see from Figure 4, the most stable isomers of SiS_m^- (m = 1-4) can be obtained by binding one S atom to the Si atom of the most stable isomers of SiS_{m-1}^- with the exception of SiS_4^- , whose structure is the fourth S atom attaches to one of the three S atoms of SiS_3^- . For $Si_2S_m^-$ (m = 1-4), the most stable structures can be derived by attaching one S atom to one of the Si atoms of the most stable structure of $Si_2S_{m-1}^-$. For the neutral Si_nS_m (n = 1,2; m = 1-4) clusters, their most stable isomers are all much lower in energy than the other isomers (Figure 5). The comparison

of the structures of anionic and neutral Si_nS_m clusters indicates that the structures are charge dependent, and the broad features observed in our experiments also indicate that there is a significant geometry change between the anions and the neutrals, therefore, the experimental ADEs of $Si_nS_m^-$ anions cannot be simply considered as the electron affinities (EAs) of Si_nS_m neutrals.

It would be interesting to compare the structures of Si_nS_m (n = 1,2; m = 1-4) clusters with their isoelectronic counterparts such as Si_nO_m and C_nS_m clusters which were investigated previously by a number of experiments and theoretical calculations.^{43,45,47–57} The earlier theoretical calculations⁴⁹ suggested that the lowest-energy structures of the neutral Si_nO_m (n = 1,2; m = 1-4) clusters are all planar structures. The most stable structures of Si_nS_m (n = 1,2; m = 1-4) clusters are similar to those of Si_nO_m except that Si_2S_2 has a bent non-planar structure which is slightly different from the planar rhombus of Si₂O₂. Maity et al.⁵² predicted that the most stable structures of CS₃ and CS₄ clusters are both C_{2v} symmetric planar structures. The most stable structures of SiS_3 and SiS_4 in this work are similar to those of CS_3 and CS_4 . However, the structures of Si_2S and Si_2S_2 are very different from those of C_2S and C_2S_2 . The most stable structures of C_2S^{55} is found to be linear with the S atom attaching to one end of C=C bond and that of C_2S_2 is also linear with the S atoms attaching to two ends of C=C bond.⁵⁶ In this work, the most stable structures of Si_2S and Si_2S_2 are both cyclic structures instead of linear structures. The structural differences between Si_2S_m and C_2S_m (m = 1,2) probably are because the two carbon atoms prefer to form bonds with each other via sp^2 hybridization while the silicon atoms prefer sp^3 hybridization.

IV. CONCLUSIONS

 $Si_nS_m^-$ (n = 1,2; m = 1-4) cluster anions were investigated with photoelectron spectroscopy. The structures of these cluster anions and their corresponding neutrals were also studied by *ab initio* calculations. The most probable structures of the $Si_nS_m^-$ clusters were determined by comparing the calculated VDEs to the experimental results. We found that the most stable isomers of the $Si_nS_m^-$ (n = 1,2; m = 1-4) clusters prefer to adopt planar structures except that $Si_2S_4^-$ has a non-planar structure with one S atom bent out of the plane. The neutral Si_nS_m (n = 1,2; m = 1-4) clusters also prefer to adopt planar structures except that the structure of Si_2S_2 is slightly bent. The Si atom is inclined to interact with more S atoms.

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